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APPLICATION NO. FILING DATE FIRST NAMED INVENTOR ATTORNEY DOCKET NO.

09/528,296

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TAKADA

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EXAMINER

NADAV, 0

ART UNIT

PAPER NUMBER

2811

DATE MAILED:

05/09/01

Please find below and/or attached an Office communication concerning this application or proceeding.

Commissioner of Patents and Trad marks



Office Action Summary

Application No. 09/528,296

Applicant(s)

Takada

Examiner

ORI NADAV

Art Unit **2811**

	The MAILING DATE of this communication appears	on the cover sheet with th	e correspondence address
	or Reply Ortened Statutory Period for Reply is set	TO EXPIRE 3	MONTH(S) FROM
THE N	MAILING DATE OF THIS COMMUNICATION.		
- Exten	isions of time may be available under the provisions of 37 Cl ter SIX (6) MONTHS from the mailing date of this communic	R 1.136 (a). In no event, ho ation.	wever, may a reply be timely filed
- If the	period for reply specified above is less than thirty (30) days	a reply within the statutory	minimum of thirty (30) days will
- If NO	considered timely. period for reply is specified above, the maximum statutory	period will apply and will expi	re SIX (6) MONTHS from the mailing date of this
- Failur - Any r	mmunication. e to reply within the set or extended period for reply will, by eply received by the Office later than three months after the rned patent term adjustment. See 37 CFR 1.704(b).	statute, cause the applicatio mailing date of this commun	n to become ABANDONED (35 U.S.C. § 133). ication, even if timely filed, may reduce any
Status			
1) 💢	Responsive to communication(s) filed on Apr 28, 2	001	•
2a) 🗌	This action is FINAL . 2b) 💢 This action is non-final.		
3) 🗆	Since this application is in condition for allowance except for formal matters, prosecution as to the merits is closed in accordance with the practice under <i>Ex parte Quayle</i> , 1935 C.D. 11; 453 O.G. 213.		
Disposi	tion of Claims		
4) 💢	Claim(s) <u>1-12</u>		_ is/are pending in the application.
4	la) Of the above, claim(s) <u>8-12</u>		is/are withdrawn from consideration.
5) 🗆	Claim(s)		is/are allowed.
6) 💢	Claim(s) <u>1-7</u>		is/are rejected.
7) 🗆	Claim(s)		is/are objected to.
8) 🗆	Claims	are subject to	restriction and/or election requirement.
Applica	tion Papers		
9) 🗆	The specification is objected to by the Examiner.		
10)💢	The drawing(s) filed on Mar 17, 2000 is/are	objected to by the Exam	iner.
11)	The proposed drawing correction filed on is: a) approved b) disapproved.		
12)	The oath or declaration is objected to by the Exam	ner.	
Priority	under 35 U.S.C. § 119		,
13)💢	Acknowledgement is made of a claim for foreign p	riority under 35 U.S.C. §	119(a)-(d).
a) 🕽	All b) □ Some* c) □ None of:		
	1. X Certified copies of the priority documents have	e been received.	
	2. Certified copies of the priority documents have		
	 Copies of the certified copies of the priority of application from the International Bure ee the attached detailed Office action for a list of the 	au (PCT Rule 17.2(a)).	
14)	Acknowledgement is made of a claim for domestic		
	•		
Attachm	ent(s) otice of References Cited (PTO-892)	18) Interview Summary (PTO-4	113) Paper No(s).
74	otice of Draftsperson's Patent Drawing Review (PTO-948)	19) Notice of Informal Patent A	
	formation Disclosure Statement(s) (PTO-1449) Paper No(s)3	20) Other:	

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DETAILED ACTION

Election/Restriction

1. Applicant's election without traverse of claims 1-7 in Paper No. 5 is acknowledged.

Drawings

- 2. Figures 3-5 should be designated by a legend such as --Prior Art-- because only that which is old is illustrated. See MPEP § 608.02(g).
- 3. The drawings are objected to because in figure 7, "453h" should read "453b". Correction is required.

Claim Rejections - 35 USC § 112

4. The following is a quotation of the second paragraph of 35 U.S.C. 112:

The specification shall conclude with one or more claims particularly pointing out and distinctly claiming the subject matter which the applicant regards as his invention.

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5. Claims 1-7 are rejected under 35 U.S.C. 112, second paragraph, as being indefinite for failing to particularly point out and distinctly claim the subject matter which applicant regards as the invention.

The claimed limitation of two conductive walls being offset with respect to one another in a direction parallel to a principal surface of the substrate toward an interior of the substrate, as recited in claim 1, is unclear as how a direction can be parallel to the surface of the substrate and inside the substrate at the same time.

Claim Rejections - 35 USC § 103

- 6. The following is a quotation of 35 U.S.C. 103(a) which forms the basis for all obviousness rejections set forth in this Office action:
 - (a) A patent may not be obtained though the invention is not identically disclosed or described as set forth in section 102 of this title, if the differences between the subject matter sought to be patented and the prior art are such that the subject matter as a whole would have been obvious at the time the invention was made to a person having ordinary skill in the art to which said subject matter pertains. Patentability shall not be negatived by the manner in which the invention was made.
- 7. Claims 1-6, insofar as in compliance with 35 U.S.C. 112, rejected under 35 U.S.C. 103(a) as being unpatentable over Iwase et al. (Jp 7-201855) in view Admitted Prior Art (APA).

lwase et al. teach in figure 2 substantially the entire claimed structure, including semiconductor device comprising a substrate, and a multi layer interconnection structure formed on the substrate (figure 2b) including an ILD film 7 and a guard ring 4

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having a straight line form and a zig-zag pattern parallel to the substrate embedded in the ILD film continuously along a periphery of the substrate, and including a conductive wall 3a of a zig-zag pattern corresponding to the guard ring pattern in the ILD film, and a conductive pattern 3a of a zig-zag pattern making contact with a top part of the conductive wall and having a principal surface coincident to the top surface of the of ILD film.

lwase et al. do not teach a guard ring having two ILD films.

APA teaches in figure 2 a guard ring 12 parallel to the substrate and embedded in first and second ILD films 24, 25 along a periphery of the substrate, including conductive walls 25C in each ILD film from a bottom principal surface to a top principal surface thereof, and a conductive pattern 25a making contact with a top part of the conductive wall and having a principal surface coincident to the top surface of the of ILD film. It would have been obvious to a person of ordinary skill in the art at the time the invention was made to use a guard ring comprising two ILD films in Iwase et al.'s device in order to provide better protection to the device, by a conventional method, of which official notice may be taken.

Regarding claim 5, APA teaches conductive wall and the conductive pattern comprising Cu (page 4).

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Regarding claim 6, APA teaches in figure 2 first and second ILD films supporting the conductive wall and the conductive pattern, laterally.

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8. Claim 7, insofar as in compliance with 35 U.S.C. 112, rejected under 35 U.S.C. 103(a) as being unpatentable over Iwase et al. and Admitted Prior Art (APA), as applied to claim 6 above, and further in view of Japanese Patent #10-335456. lwase et al. and APA teach substantially the entire claimed structure, as applied to claim 6 above, except an etch stop layer interposed between the first and second ILD films.

Japanese Patent #10-335456 in figure 7 an etch stop layer 54 interposed between the first and second ILD films 52, 58 (abstract).

It would have been obvious to a person of ordinary skill in the art at the time the invention was made to use an etch stop layer interposed between the first and second ILD films in the device of Iwase et al. and APA, in order to simplify and improve the processing steps of making the device. Note that it is conventional to form multi layer metalization using an etch stop layer, of which official notice may be taken.

9. The prior art made of record and not relied upon is considered pertinent to applicant's disclosure. References A-B are cited as being related to a guard ring having a zig-zag pattern.

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Papers related to this application may be submitted to Technology center (TC) 2800 by facsimile transmission. Papers should be faxed to TC 2800 via the TC 2800 Fax center located in Crystal Plaza 4, room 4-C23. The faxing of such papers must conform with the notice published in the Official Gazette, 1096 OG 30 (November 15, 1989). The Group 2811 Fax Center number is (703) 308-7722 and 308-7724. The Group 2811 Fax Center is to be used only for papers related to Group 2811 applications.

Any inquiry concerning this communication or any earlier communication from the Examiner should be directed to *Examiner Nadav* whose telephone number is (703) 308-8138. The Examiner is in the Office generally between the hours of 7 AM to 3 PM (Eastern Standard Time) Monday through Friday. If attempts to reach the examiner by telephone are unsuccessful, the examiner's supervisor, Tom Thomas, can be reached at (703) 308-2772.

Any inquiry of a general nature or relating to the status of this application should be directed to the **Technology Center Receptionists** whose telephone number is **308-0956**

Ori Nadav, Ph.D.

May 6, 2001

William Mintel Primary Examiner Art Unit 2811

William Mintel